



AF ZTW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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| Application of: | Peyne et al. | Confirmation No.: | 3734 |
| Serial No.: | 10/007,134 | Art Unit: | 2823 |
| Filed: | December 4, 2001 | Examiner: | Maldonado, Julio J. |
| For: | POST ETCH CLEANING COMPOSITION FOR DUAL DAMASCENE SYSTEM | Attorney Docket No.: | 060937-0123 |

AMENDMENT AFTER FINAL REJECTION

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ZLL
09/19/06*
U.S. Patent and Trademark Office
Randolph Building
401 Dulany Street
Alexandria, Virginia 22314 – **MAIL STOP AF**

Sir:

This Amendment is in response to the Final Office Action dated July 5, 2006 for the above identified patent application.

Amendments to the Claims are reflected in the listing of claims, which begin on page 2, and,

Remarks being on page 12 of this Amendment.